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Optically excited multi-band conduction in LaAlO$_3$/SrTiO$_3$ heterostructures


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The low-temperature resistance of a conducting LaAlO$_3$/SrTiO$_3$ interface with a 10nm LaAlO$_3$ film decreases by more than 50% after illumination with light of energy higher than the SrTiO$_3$ band-gap. We explain our observations by optical excitation of an additional high mobility electron channel, which is spatially separated from the photo-excited holes. After illumination, we measure a strongly non-linear Hall resistance which is governed by the concentration and mobility of the photo-excited carriers. This can be explained within a two-carrier model where illumination creates a high mobility electron channel in addition to a low mobility electron channel which exists before illumination. © 2013 American Institute of Physics. [http://dx.doi.org/10.1063/1.4790844]

A conducting interface between band-insulating perovskites LaAlO$_3$ (LAO) and SrTiO$_3$ (STO) displays a wide variety of physical phenomena, such as superconductivity, magnetism, and quantum oscillations with 2D character. Several mechanisms are suggested to describe the origin of conductivity at the LAO/STO interface. However, the relative contribution of each mechanism appears to depend on the LAO film thickness and on the LAO growth conditions such as substrate temperature, oxygen partial pressure, and the post annealing treatment; the complete picture of the involved mechanisms is not yet clear. In particular, growing 5–10 layers of LAO on STO yields a metallic interface with relatively high mobility and low electron concentration, whereas growing 26 LAO layers with the same conditions results in a low mobility, high concentration electron system with interesting magnetic properties. Tuning the transport properties at such a complex oxide interface by modulating the carrier density with light can both contribute to the understanding of its physics and open new pathways towards oxide-based optoelectronic device applications. It has been shown previously that interface conductivity in oxide heterostructures can be tuned by light or by an electric field.

In this letter we report our investigation of the interface of a LAO/STO sample with 26 monolayers of LAO, using low-temperature (4.2 K) magnetotransport experiments under selective illumination. Illuminating the sample with UV light of energy greater than the STO band gap results in a sharp and persistent decrease of electrical resistance. Using Hall effect measurements, we show that before illumination there is a single, low mobility electron conduction band and that the resistance drop on illumination can be explained by the creation of a parallel conducting channel containing optically excited high mobility electrons.

Our sample was grown by pulsed laser deposition (PLD) and has a 10nm thick (26 unit cells) LAO film on a TiO$_2$-terminated single crystal STO [001] substrate (treatment described in Ref. 26). The LAO film was deposited at a substrate temperature of 850°C and an oxygen pressure of 2 × 10$^{-3}$ mbar, using a single-crystal LaAlO$_3$ target. The growth of the LAO film was monitored using in situ reflection high-energy electron diffraction. After the growth, samples were cooled to room temperature in the deposition pressure.

The sample was mounted on a ceramic chip carrier, and electrical contacts were made with an ultrasonic wirebonder, using aluminium wires. The magnetoresistance and Hall resistance were measured at 4.2 K in a van der Pauw geometry, using a standard low-frequency lock-in technique with an excitation current of 1 μA. The temperature dependence of the sample resistance shows a low-temperature upturn, similar to that observed previously by Brinkman et al. The sample was illuminated with light from a broad-band Xe-lamp (LSB521), which was filtered using a 30 cm single grating monochromator (Acton-SP2300) as well as longpass and bandpass filters, to tune the excitation energy. The obtained quasi monochromatic light (Δλ ≈ 3nm) was brought to the sample via an optical fiber.

In Fig. 1, we show raw data of the sample resistance as a function of time during light illumination in the energy range between 1.44 and 3.65 eV. Each step corresponds to a constant illumination with a specific energy during 1 min (light “ON”). After illumination, we waited for 10 min to allow the resistance to reach a reasonably stable value (light “OFF”), before illuminating with the next photon energy. The influence of photons with different energy is clearly seen as a series of steps in the sample resistance. When the energy of illuminating photons is smaller than the band gap of STO (3.4 eV), a small resistance decrease is observed. This small change in the sample resistance can be due to the finite absorption of incident illumination by in-gap states present inside the STO band gap. When the photon energy is approaching the band gap of STO, there is a gradual increase in the change of sample resistance. The largest drop in resistance (more than 50%) occurs when the photon energy...
(3.65 eV) exceeds the STO band gap energy (3.4 eV). This dramatically reduced resistance does not recover to the initial value after the illumination is turned off and only returns to the previous value when the sample is heated to room temperature. Repeated thermal cycling of the sample gave reproducible results.

We performed a control experiment on a STO[001] substrate, which was subjected to a similar chemical etching and annealing treatment (described in Ref. 26). The TiO2-terminated bulk STO[001] substrate was heated to a temperature of 850 °C at an oxygen pressure of 2 × 10⁻³ mbar in the PLD chamber, without depositing the LAO layer. When illuminating this treated control sample, under similar illumination conditions as for the LAO/STO interface, we found that it remains insulating for all photon energies. This proves that the persistent resistance decrease is a feature of the LAO/STO interface and not an effect from the treated bulk STO[001] substrate.

In Fig. 2, we show as open circles (right axis), the variation in the number of illuminating photons as a function of photon energy, which is a consequence of the energy-dependent throughput of the optical set-up. The number of photons at the sample was calculated from the integration over time of the total power incident on the sample, normalized with the energy of a single photon. The solid circles (left axis) show the resistance change of the sample, normalized by the number of incident photons, at each photon energy. The most drastic change occurs when the photon energy is higher than the STO band gap, shown as the vertical dashed line in the figure.

In order to explain these results, we propose the generation of additional, photo-excited carriers, as depicted in the inset of Fig. 1: Illuminating either the bulk STO (control sample) or the LAO/STO heterostructure with photon energy higher than the band gap of STO creates electron-hole pairs in the STO substrate. In the case of bulk STO, the photo-excited electrons in the empty conduction band do not persist for a long time and recombine very quickly with holes in the valence band, or through other recombination centres. For the case of LAO/STO heterostructure, the photo-excited electrons move to the interface potential well, where the holes remain trapped in the substrate. Owing to this spatial separation, electron and hole wavefunctions do not overlap, and direct optical recombination is suppressed, leading to a persistent resistance change.

For the LAO/STO heterostructure, the interface potential lifts the degeneracy of the STO bulk bands (Ti-3d xy, yz, and xz orbitals), and a further formation of 2D subbands is expected due to spin-orbit coupling and the internal electric field due to growth of LAO layers.29 The 2D interface potential well gives a multi-subband character to the STO conduction band at the interface of LAO/STO.11 Owing to this multi-subband structure of the interface, we propose that the photo-excited carriers occupy an initially unoccupied subband with a high mobility.

To study the nature of the persistent photo-excited carriers, we have performed magnetotransport experiments after illumination with an increasing total number of photons $N_{tot}$, controlled with neutral density filters, at a constant photon energy of 3.65 eV. In Fig. 3(a), we show the Hall resistance $R_{xy}$ as a function of applied magnetic field $B$ at 4.2 K, before illumination and after illuminating with four different values of $N_{tot}$.
of $N_{\text{tot}}$ (open symbols). The corresponding (longitudinal) magnetoresistance is shown in Fig. 3(b). Without any illumination, a linear Hall resistance and a small negative magnetoresistance are observed, in agreement with earlier observations on a similar sample. After illumination, a distinctly non-linear Hall resistance and a large positive magnetoresistance appear.

We describe the linear Hall resistance using the conventional single-carrier model and extract the carrier concentration ($n = B/R_{xy}$) and mobility ($\mu = 1/\rho_0 e n$) from the slope of the linear fit to the data—the fit is shown as a solid line in Fig. 3(a), where $\rho_0$ is the zero-field sheet resistance and $e$ is the electronic charge. This yields a carrier density $n_1 = 8.9 \times 10^{13}$ cm$^{-2}$ and a mobility $\mu_1 = 3$ cm$^2$/Vs. This very low carrier mobility is similar to values previously observed in LAO/STO samples with comparable LAO layer thickness.

In contrast, the non-linear Hall resistance after illumination cannot be explained within a single-carrier model but rather suggests a multi-channel system. A similar non-linear behavior has been observed in SrTiO$_3$/LaTiO$_3$.

The values of $n_1$ and $\mu_1$ extracted in this way are shown in the supplementary material. We suggest that these persistently photo-excited carriers occupy one of the interface 2D subbands in STO, where these carriers have relatively higher mobility than the existing low mobility carriers without illumination.

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